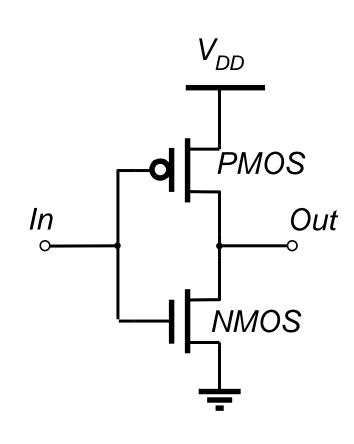


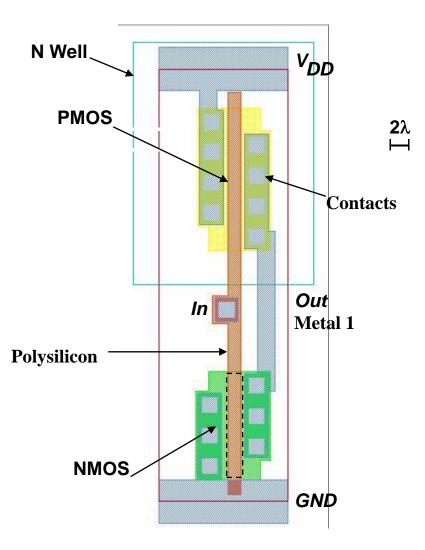
ECE 122A VLSI Principles Lecture 8

Prof. Kaustav Banerjee Electrical and Computer Engineering University of California, Santa Barbara *E-mail: kaustav@ece.ucsb.edu*

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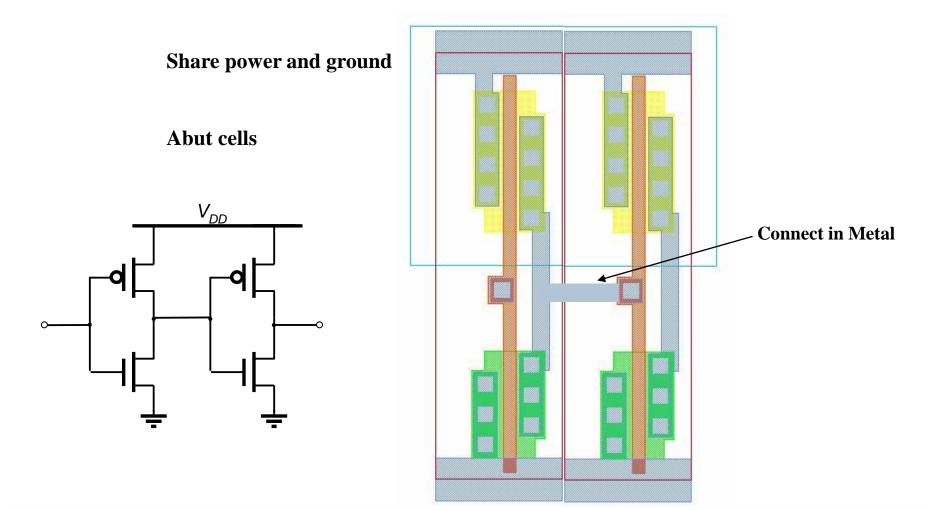
CMOS Inverter



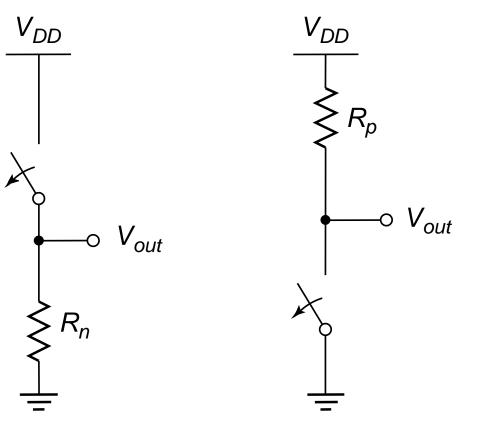


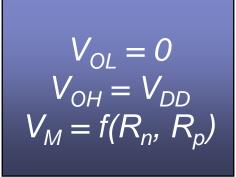
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Two Inverters



CMOS Inverter First-Order DC Analysis



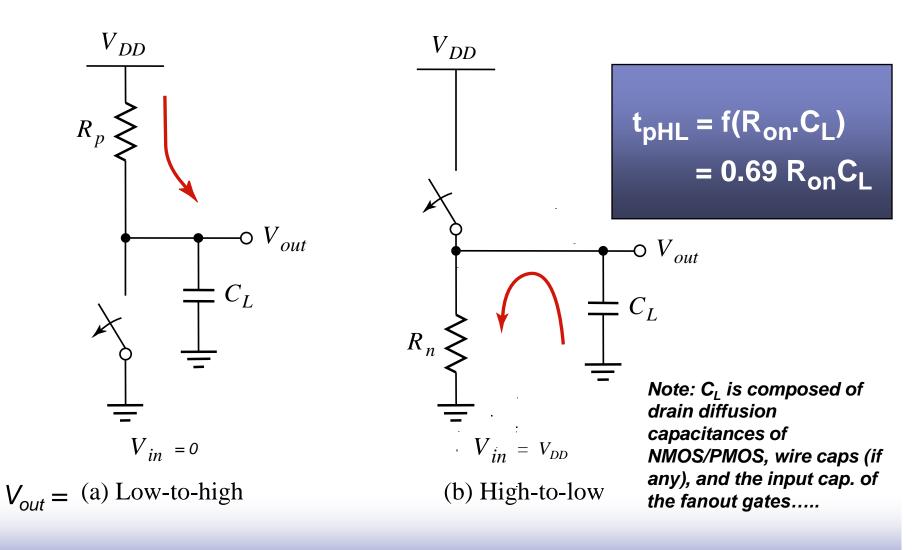


 $V_{in} = V_{DD}$

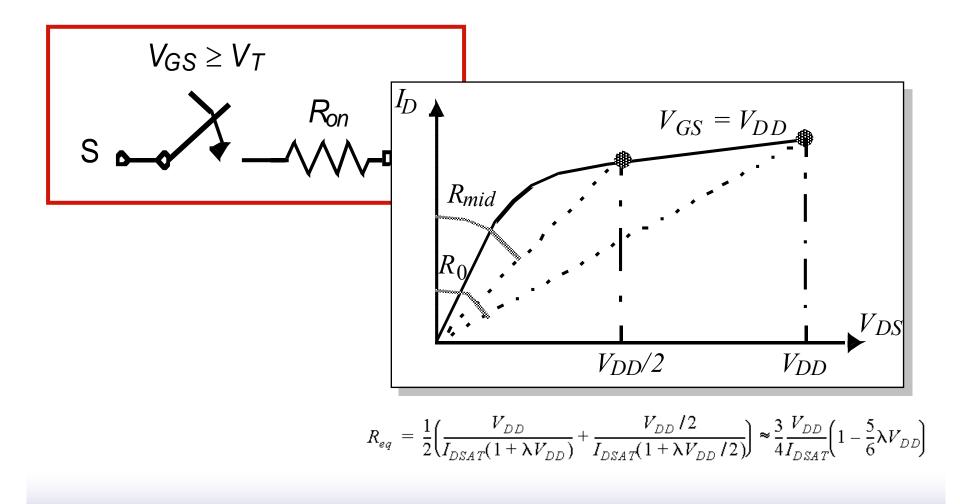
$$V_{in} = 0$$

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CMOS Inverter: Transient Response

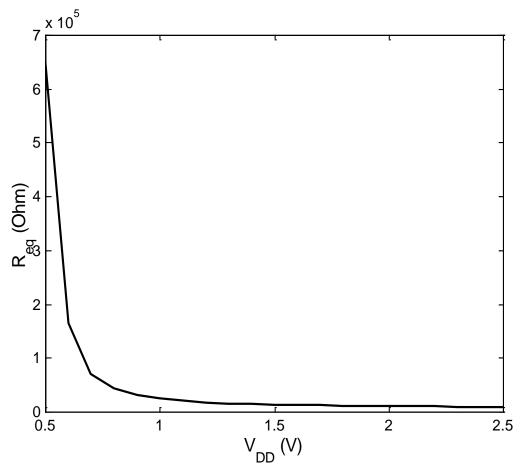


The Transistor as a Switch



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The Transistor as a Switch



As V_{DD} increases, drain current increases....for both NMOS and PMOS

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The Transistor as a Switch

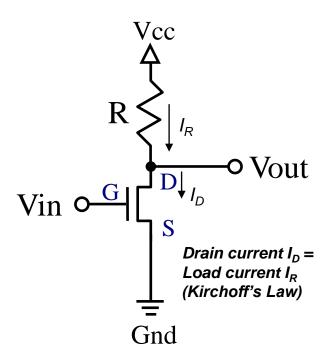
Table 3.3 Equivalent resistance R_{eq} (*W*/*L*= 1) of NMOS and PMOS transistors in 0.25 µm CMOS process (with $L = L_{min}$). For larger devices, divide R_{eq} by *W*/*L*.

V_{DD} (V)	1	1.5	2	2.5
NMOS (kΩ)	35	19	15	13
PMOS (kΩ)	115	55	38	31

Resistive-load Inverter

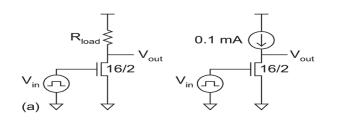
- Requires only NMOS transistor and resistor
- **u** When Vin = 0:
 - NMOS is OFF ($V_{GS} = 0$)
 - No current through NMOS
 - Vout ≈ Vcc
- \Box When Vin = Vcc:
 - NMOS is ON (V_{GS} = Vcc)
 - NMOS ON resistance << R</p>
 - Vout ≈ 0

Not suitable for VLSI: large area of R, DC power dissipation.

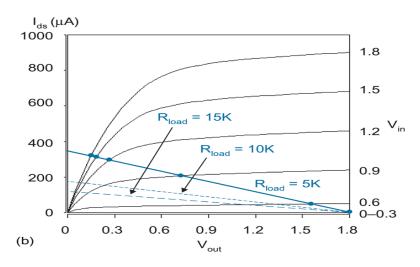


Remember: if body terminal not shown, it is connected to gnd for NMOS, Vcc for PMOS

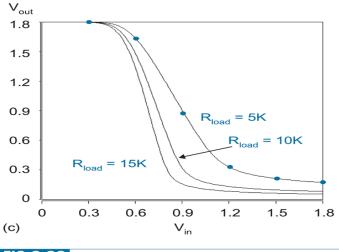
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Resistive-load Inverter



$$I_{ds} = V_{cc} / R_{load}$$





As R_{load} increases, V_{TC} becomes sharper!

Larger R_{load} = smaller PU transistor...LO skewed...

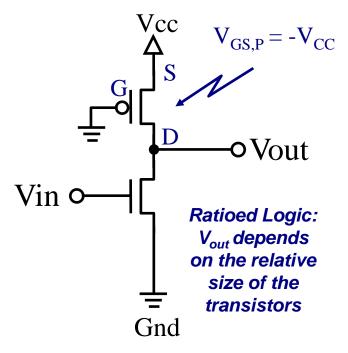
Kaustav Banerjee

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Pseudo-NMOS Inverter

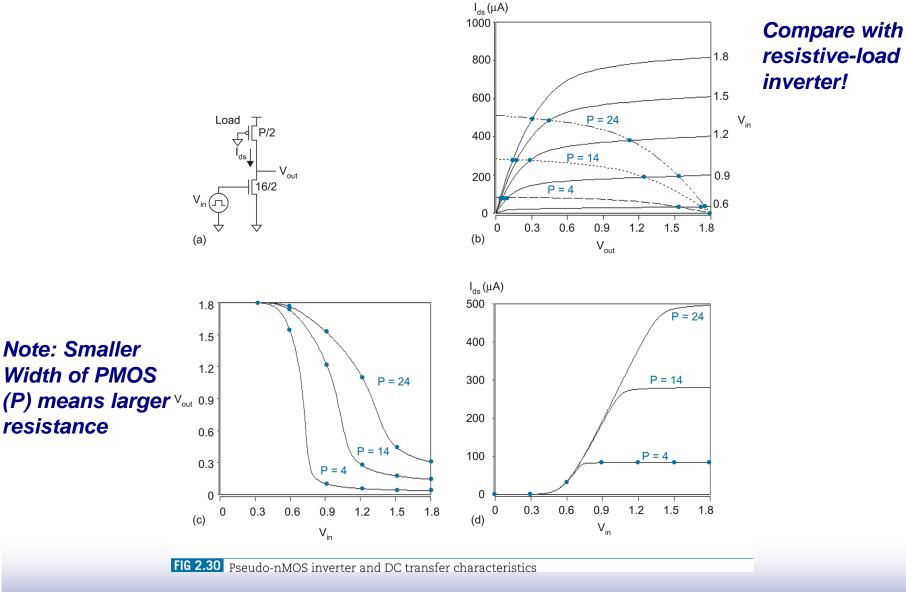
- Replace resistor with "alwayson" PMOS transistor
- Easier to implement in standard process than large resistance value
- PMOS load transistor:
 - ON when $V_{GS} < V_T \rightarrow V_{GS} = -V_{CC}$: transistor always on
 - Linear when $V_{DS} > V_{GS} V_T \rightarrow V_{out} V_{cc} > -V_{cc} V_T \rightarrow V_{out} > -V_T$
 - Saturated when $V_{DS} < V_{GS} V_T \rightarrow$

$$V_{out}$$
- V_{cc} < - V_{cc} - V_{T} \rightarrow V_{out} < - V_{T}
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Remember: $V_T(PMOS) < 0$

Pseudo-NMOS Inverter

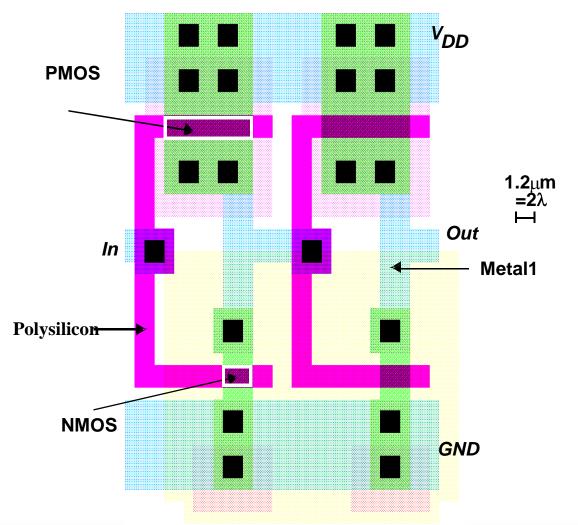


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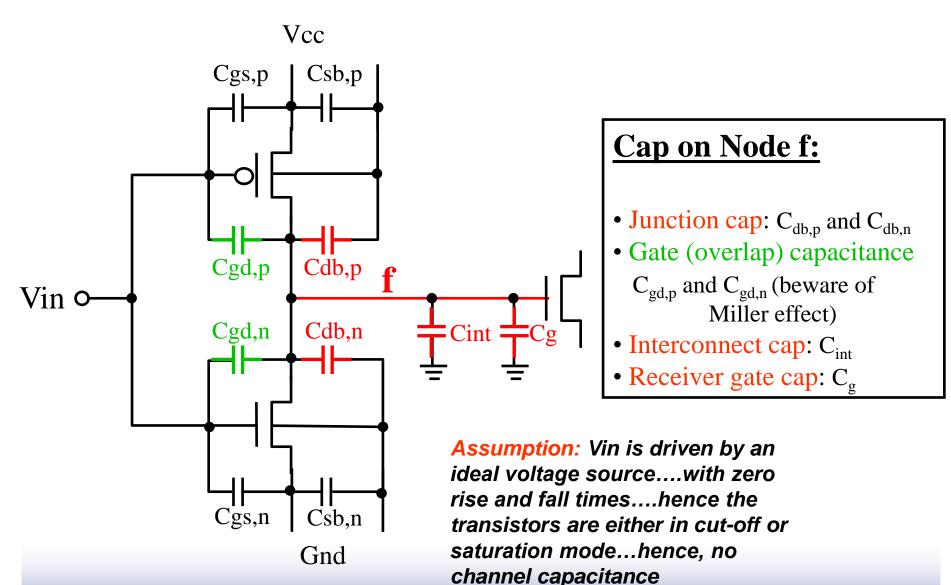
Propagation Delay

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Two CMOS Inverters...

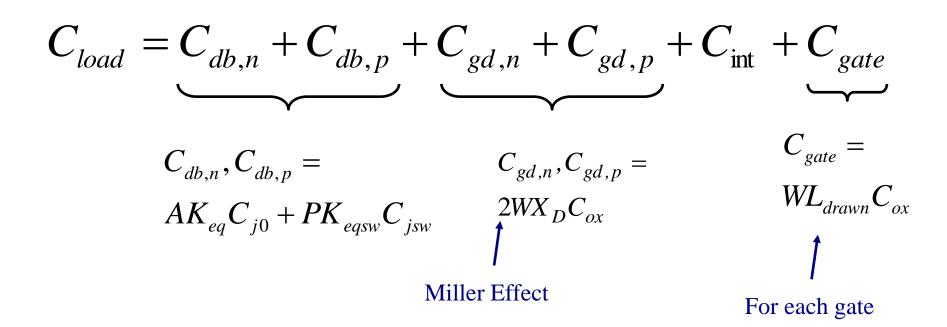


CMOS inverter capacitances

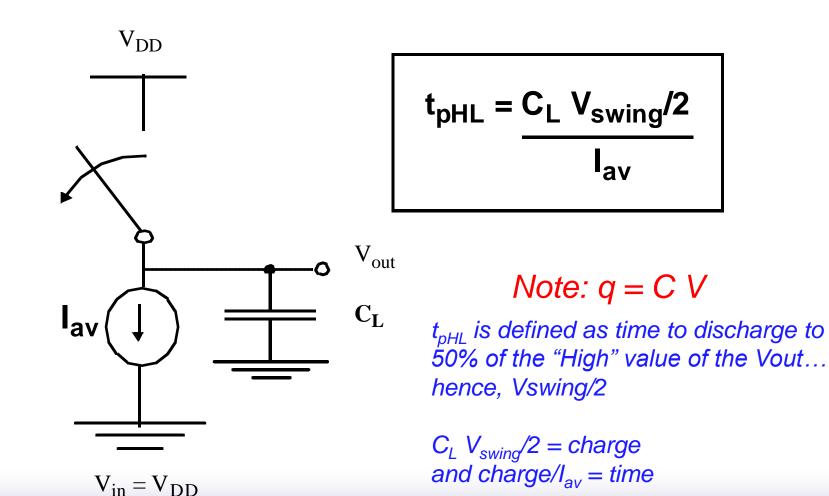


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CMOS inverter capacitances

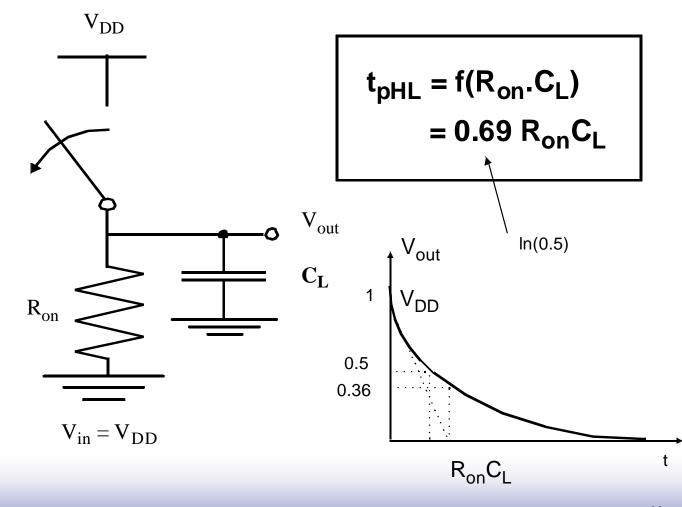


CMOS Inverter Propagation Delay Approach 1



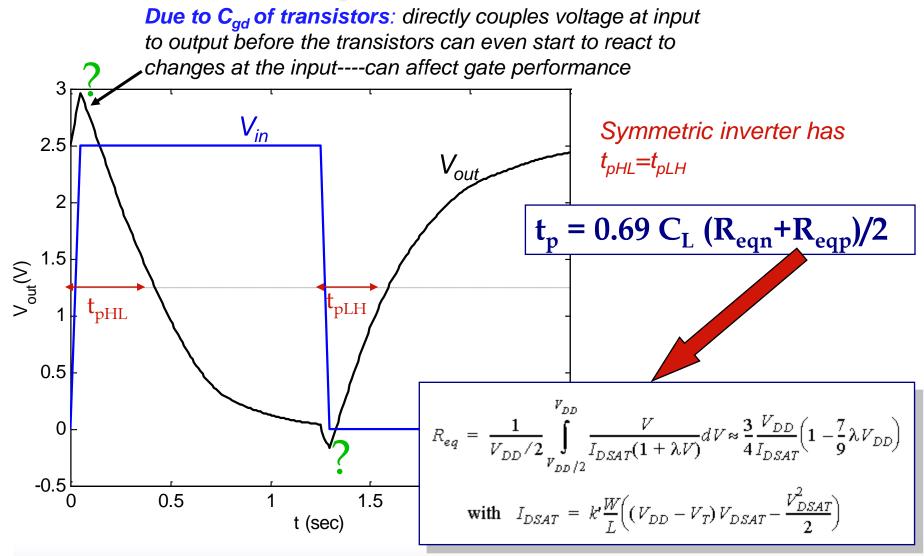
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CMOS Inverter Propagation Delay Approach 2



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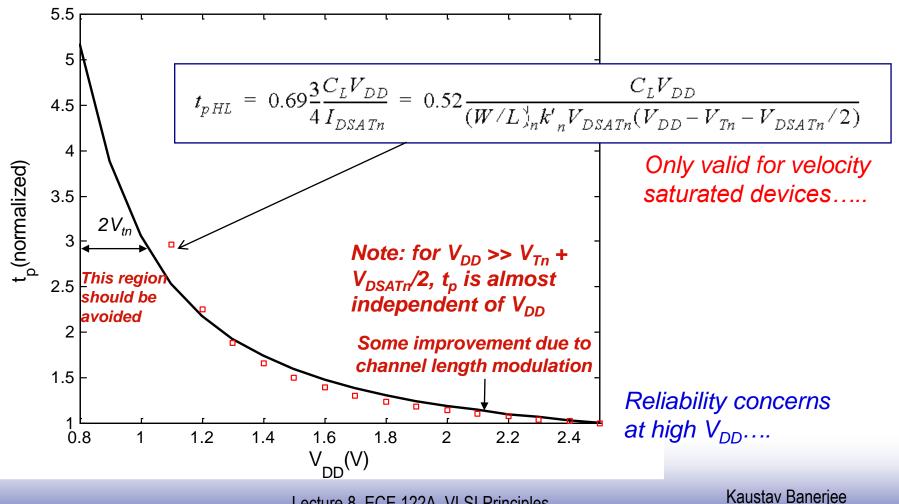
Transient Response



CMOS Inverter Delay as a function of V_{DD}

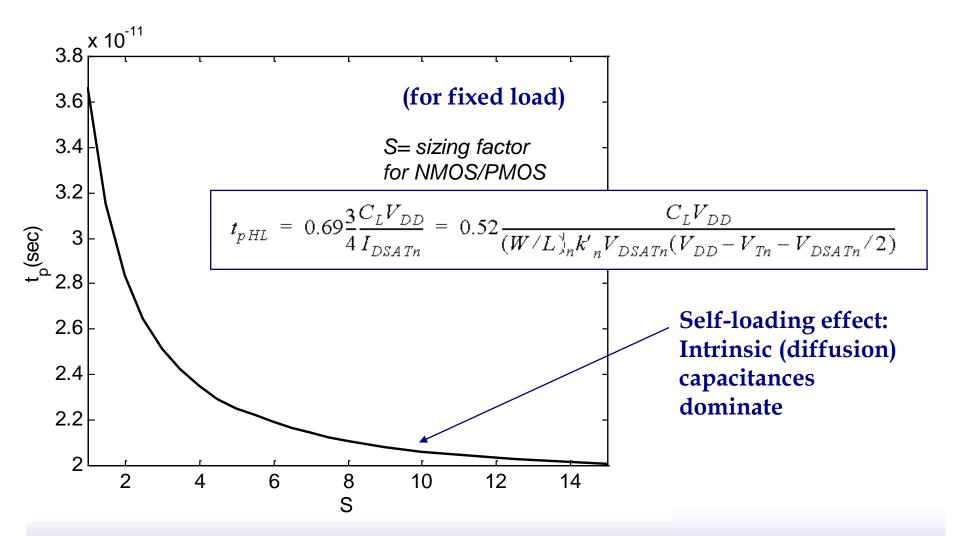
Same trend as the ON resistance of a transistor....

Trade off energy dissipation vs performance.....

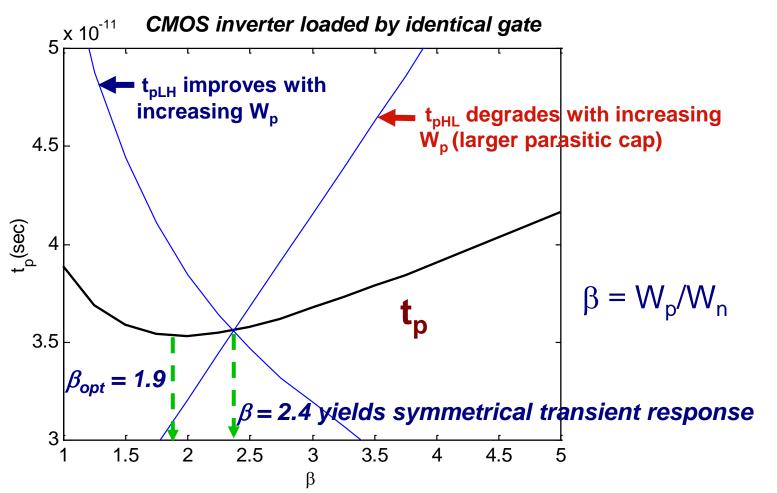


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Effect of Device Sizing



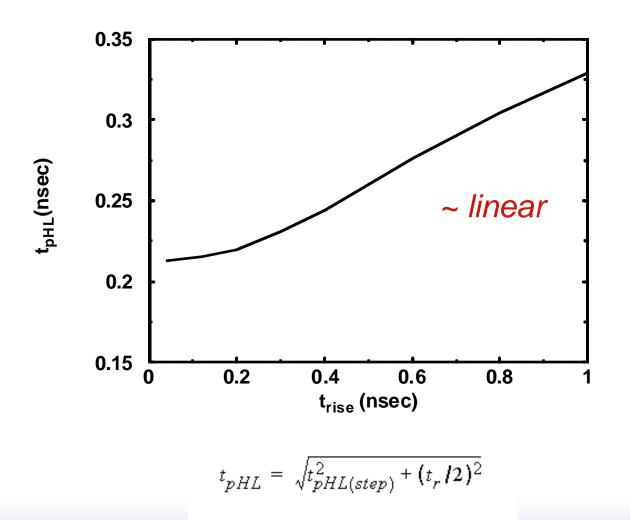
NMOS/PMOS ratio



If symmetry and noise margins are not of prime concern, inverter delay can be reduced by reducing the width of PMOS....

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Impact of Rise Time on Delay



As the input signal changes gradually, both PMOS and NMOS conduct simultaneously....

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Design for Performance

□ Keep load capacitances (C_L) small

- Recall that three major components contribute to the load cap.
 - internal diffusion + overlap caps
 - interconnect cap.
 - -fan-out (gate cap)
- Increase transistor sizes
 - watch out for self-loading!
- □ Increase V_{DD} (??)
 - watch out for reliability issues!

Power Dissipation

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Where Does Power Go in CMOS?

Dynamic Power

Due to charging/discharging of capacitors....

Leakage Power

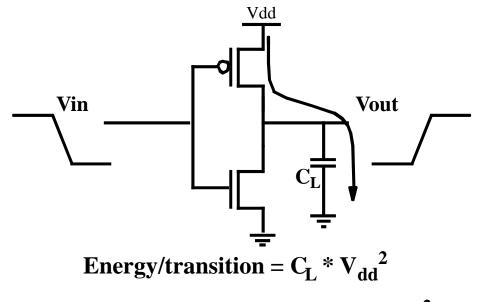
- Subthreshold
- Gate
- Junction

Short-Circuit Power

When NMOS and PMOS are both turned ON....

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Dynamic Power Dissipation



Note: Here C_L is an external capacitor....

Power = Energy/transition $*f = C_L * V_{dd}^2 * f$

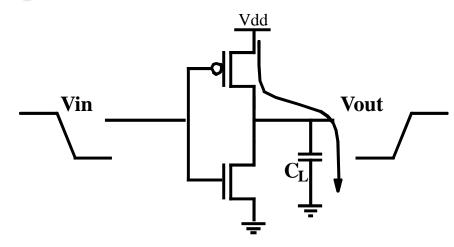
- Energy/transition is not a function of transistor sizes!
- Need to reduce C_L, V_{dd}, and *f* to reduce power.

Energy taken from supply during transition:

$$E_{V_{DD}} = \int_{0}^{\infty} i_{V_{DD}}(t) V_{DD} dt = V_{DD} \int_{0}^{\infty} C_{L} \frac{dv_{out}}{dt} dt = C_{L} V_{DD} \int_{0}^{V_{DD}} dv_{out} = C_{L} V_{DD}^{2}$$

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Dynamic Power Dissipation



Note: during the discharge phase, charge is removed from C_L and its energy is dissipated in the NMOS

Energy taken from supply during transition:

$$E_{V_{DD}} = \int_{0}^{\infty} i_{V_{DD}}(t) V_{DD} dt = V_{DD} \int_{0}^{\infty} C_{L} \frac{dv_{out}}{dt} dt = C_{L} V_{DD} \int_{0}^{V_{DD}} dv_{out} = C_{L} V_{DD}^{2}$$

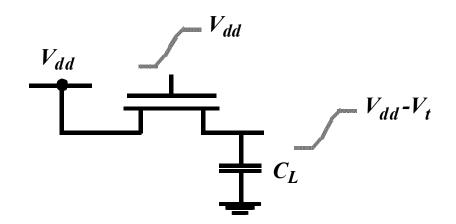
Energy stored in the capacitor:

$$E_{C} = \int_{0}^{\infty} i_{V_{DD}}(t) v_{out} dt = \int_{0}^{\infty} C_{L} \frac{dv_{out}}{dt} v_{out} dt = C_{L} \int_{0}^{V_{DD}} v_{out} dv_{out} = \frac{C_{L} V_{DD}^{2}}{2}$$

Where is the other half of the energy?Dissipated by the PMOS

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Modification for Circuits with Reduced Swing

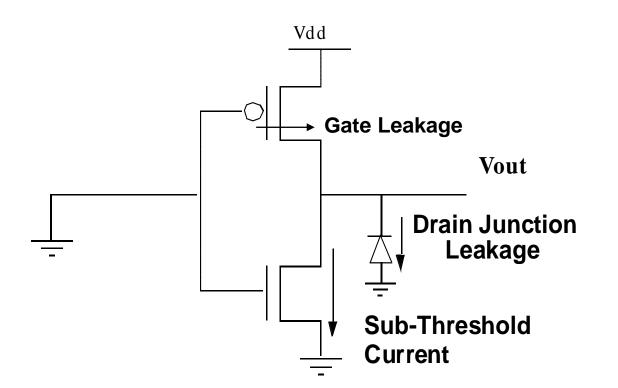


$$\mathbf{E}_{0 \to 1} = \mathbf{C}_{L} \bullet \mathbf{V}_{dd} \bullet (\mathbf{V}_{dd} - \mathbf{V}_{t})$$

Same as previous equation for energy drawn from supply voltage ($C_L V_{dd}^2$).... integration of V_{out} yields (V_{dd} - V_t)

• Can exploit reduced swing to lower power (e.g., reduced bit-line swing in memory)

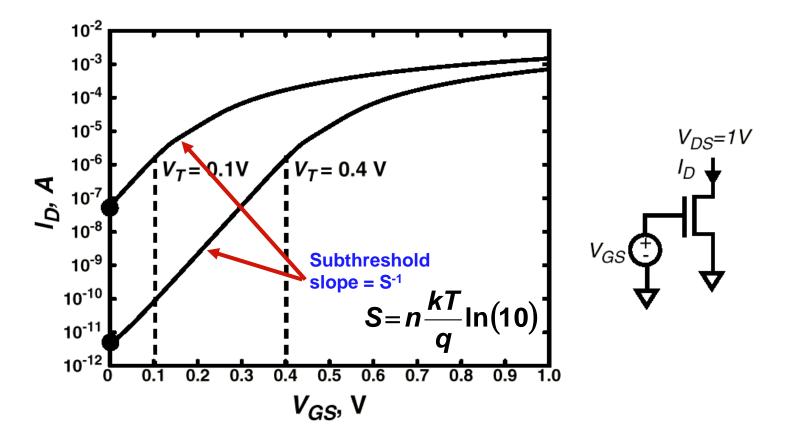
Primary Leakage Mechanisms



Sub-threshold current one of most compelling issues in low-energy circuit design!

Subthreshold Leakage Component

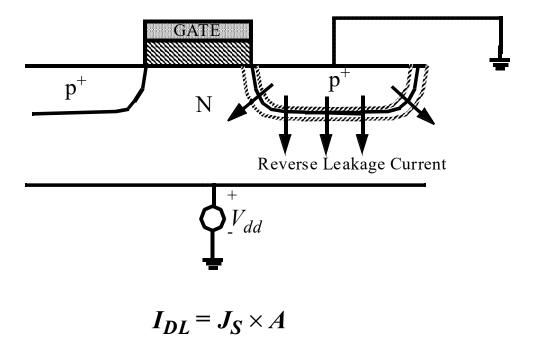
Subthreshold Swing = S = 60 mV/decade at room temperature (for ideal transistor with n=1)



Leakage control is critical for low-voltage operation

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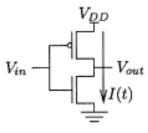
Reverse-Biased Diode Leakage



 $JS = 10-100 \text{ pA}/\mu\text{m2}$ at 25 deg C for $0.25\mu\text{m}$ CMOS JS doubles for every 9 deg C!

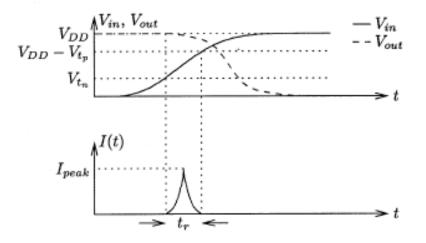
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Short Circuit Currents



(a) CMOS

inverter.



(b) Voltage and current waveforms.

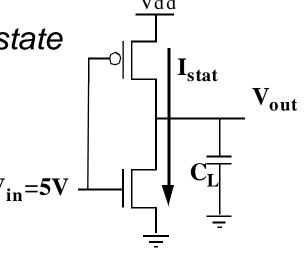
K. Banerjee and A. Mehrotra, IEEE Transactions on Electron Devices, Vol. 49, No. 11, 2002.

Fig. 5. Voltage and current waveforms of a CMOS inverter.

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Static Power Consumption

In the absence of switching....steady-state operation



Sources:

Due to all previously mentioned leakage currents.....

 $P_{stat} = P_{(In=1)} V_{dd} I_{stat}$

Wasted energy ... Should be avoided in almost all cases, but could help reducing energy in others (e.g. sense amps)

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Leakage

□ Effect of leakage current

- "Wasted" power: power consumed even when circuit is inactive
- Leakage power raises temperature of chip
- Can cause functionality problem in some circuits: memory, dynamic logic, etc.
- Reducing transistor leakage
 - Long-channel devices
 - Small drain voltage
 - Large threshold voltage V_T

Principles for Power Reduction

□ Prime choice: Reduce voltage!

- Recent years have seen an acceleration in supply voltage reduction
- Design at very low voltages still open question (~0.3-0.4V)
- Reduce switching activity
- Reduce physical capacitance
 - Device Sizing

Leakage Power Reduction

Process scaling

- V_T reduces with each new process (historically)
- Leakage increases ~10X!
- □ Leakage vs. performance tradeoff:
 - For high-speed, need small V_T and L
 - For low leakage, need high V_T and large L
- \Box One solution: dual-V_T process
 - Low-V_T transistors: use in critical paths for high speed
 - High-V_T transistors: use to reduce power



Parameters		Constant Vdd scaling	Constant E scaling	
	Width = w	0.	0.7	
Dimentions	Length = L	0.	0.7	
	Oxide thickness t _{ox}	0.	0.7	
	Junction depth X _j	0.7		
Die Area		(0.	$(0.7)^2$	
Gate capacitance per unit area ($C_{gox} = \frac{\varepsilon_{ox}}{t_{ox}}$)		$\frac{1}{0}$	$\frac{1}{0.7}$	
Gate capacitance ($C_g = wLC_{gox}$)		0	0.7	
Total Capacitance (<i>C</i>)		0	0.7	
Supply Voltage (V_{DD})		1	0.7	
Current per device ($I_{DS} \propto \frac{W}{L} \frac{\mathcal{E}_{ox}}{t_{ox}} (V_{gs} - V_{th}) V_{DD}$)		1	0.7	
Intrinsic Gate Delay ($\tau = \frac{C_g \Delta V}{I_{AV}}$)		0.7	0.7	
Frequency ($f \propto \frac{1}{\tau}$)		$\frac{1}{0.7}$		
Active Power	Active Power Dissipation ($P_{active} = CV_{DD}^2 f$)		$(0.7)^2$	
Energy-Delay Product ($CV_{DD}^2 \tau$)		$(0.7)^2 = 0.49$	$(0.7)^4 = 0.2401$	
Power Dissipation density ($\frac{P_{active}}{Area}$)		$\frac{1}{(0.7)^2} \approx 2$	$\frac{(0.7)^2}{(0.7)^2} \approx 1$	